HOW TO AVOID COMMON PITFALLS IN COMBINED EU/US PATENT APPLICATIONS

Registration

nformation

22 May 2015, Conf. No H5-3115

FORUM

Application to Register	Please PRINT your details:
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josephine.leak@management-forum.co.uk

Dates

22 May 2015

Start: 09.30 - Finish: 17.00

Registration & Coffee 22 May 2015 09.00

Venue and Accommodation

The Cavendish Hotel, 81 Jermyn Street, St James's, London, SW1Y 6JF Hotel Tel: +44 (0) 20 7930 2111 Hotel Fax:+44 (0) 20 7839 2125 Email: info@thecavendishlondon.com

Subject to availability, a limited number of bedrooms have been reserved at the hotel at a special rate.

Directions

For directions to the hotel, please visit the link below: http://www.thecavendish-london.co.uk/hotel-location

£598 & VAT* if applicable. The fee includes course documentation as well as mid-session refreshments and lunch. Invoice and confirmation will be forwarded to you.

*Reduced to £498 if you also register for the seminar on Thursday 21 May 2015 - The Impact of Patent Construction Ref. H5-3015 [Discount only applicable to the full delegate rate]

l w	ould like to attend (please tick)
	Impact of Patent Construction - Ref: H5-3015 - 21 May 2015

How to Avoid Common Pitfalls Ref: H5-3115 - 22 May 2015

For Cancellation Policy and T&Cs see website

NB: Cancellations must be received in writing by registrations@management-forum.co.uk

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If you have NOT received confirmation seven days after registering please contact registrations@management-forum.co.uk

Discounted Rates

Available on application for personnel from non-profit making organisations and registered charities. Group discount available on request



NEW, ONE-DAY, ACCELERATED WORKSHOP

HOW TO AVOID COMMON PITFALLS IN COMBINED EU/US PATENT APPLICATIONS

5.5 CPD HOURS

This workshop will cover:





- o Maximise scope of protection
- Reduce objections
- Minimise costs and maximise flexibility
- Prosecution procedures:
 - EPO and USPTO approaches to rejections
 - Responding to EPO and USPTO rejections. based on an optimised specification
 - o Limiting US prosecution history estoppel
- Worked examples







facebook

Speakers:

Bradley Hulbert McDonnell Boehnen Hulbert & Berghoff. Chicago

David Meldrum D Young & Co LLP, London

Register online at www.management-forum.co.uk or by phone on +44 (0)1483 730071, fax 730008



22 May 2015 The Cavendish Hotel, London



HOW YOU WILL BENEFIT FROM ATTENDING THIS WORKSHOP

An application originating in Europe frequently encounters substantial difficulties before the USPTO. Recurrently, claims issued to a European applicant are unnecessarily narrow by US standards or unexpectedly constrained by US principles of disavowal, disclaimer and estoppel. Claim amendments and patentability arguments that are highly effective for the EPO often prove entirely inadequate before US Patent Examiners and the PTAB.

This workshop addresses the parallel, but substantially different, rules for drafting and prosecuting patents required by the Examiners and Appeal Boards of the EPO and USPTO.

You will study the contrasting approaches of the EPO and USPTO and learn the experts' techniques for drafting an application for, and responding to, rejections issued by the two offices.

PRACTICAL APPLICATIONS

- You and the other delegates will be invited to correct and modify a sample application to be filed with both the EPO and USPTO.
- You will be asked to develop effective arguments, for the EPO and USPTO, with respect to hypothetical patent office rejections.
- The workshop will include ongoing opportunities for you to ask questions and discuss individual concerns.

WHO SHOULD ATTEND

- Patent professionals and other executives who are responsible for patent applications that are filed in, and prosecuted before, both the European and US Patent Offices.
- Managers overseeing and evaluating the multinational patent prosecution.

SPEAKERS

Bradley Hulbert is a founding partner in McDonnell Boehnen Hulbert & Berghoff, an 80-lawyer patent firm in Chicago. Mr. Hulbert has overseen the development of a diverse range of extensive, international patent portfolios and is also an adjunct professor of law at the Chicago-Kent Law School.

David Meldrum has a background in electronic engineering and is a Partner of D. Young & Co LLP, Patent and Trademark Attorneys, a large IP practice based in London and Southampton. He advises medium and large corporations on their IP strategies as well as handling patent procurement matters directly before the EPO and UKIPO and indirectly worldwide.

ATTENDANCE LIMITED – EARLY REGISTRATION RECOMMENDED

This limitation, a unique feature of all **MANAGEMENT FORUM** seminars will give participants the opportunity for a thorough discussion of the complex issues to be covered by the programme.

Reserve your place at the course by registering online now at www.management-forum.co.uk or by fax +44 (0)1483 730008. Any questions? e-mail josephine.leak@management-forum.co.uk

This workshop merits 5.5 hours CPD and may also be relevant training under the IPReg CPD self-accreditation scheme

DOCUMENTATION

Participants will receive a course material folder containing comprehensive documentation provided by the speakers, which will be a valuable source of reference for the future.

A Certificate of Attendance for Professional Development will be given to each participant who completes the workshop

Programme

- ▶ Differences in the statutory systems of the EPO and USPTO and the common consequences of drafting for only one system
 - Legal aspects
 - · Procedural aspects
 - Substantive aspects
 - Formal aspects
- 'Best Practices' for preparing one specification to comply with the European and US requirements for:
 - Priority
 - Added subject matter/new matter
 - Industrial application/utility
 - Inventive step/non-obviousness
 - Description and sufficient basis/enablement and written description
 - Claim clarity and conciseness/'distinct claiming'
 - Limiting estoppel
- **▶** EPO/US Definitions of Prior Art and Priority
 - EPC
 - o Article 54 definitions of 'State of the Art'
 - US
 - o Definitions of 'Prior Art' for anticipation and obviousness
 - o Ramifications of the America Invents Act
- ▶ Responding to EPO and UPTO rejections, based on a single, optimised specification
 - Burdens of proof
 - Use of provisional and non-provisional applications
 - Interviews/hearings
 - Inventive Step (EPO) vs Obviousness (USPTO)
 - EPO/US: Strategies for persuading the Examiner and Board
- Prosecution History Estoppel in the US
 - Estoppel variants
 - Controlling the adverse impact of arguments to the USPTO
 - · Effect of representations made in corresponding, non-US applications
- ▶ Arguments on Non-Technical (EPO) and Non-Eligible (US) Subject Matter
 - Article 52(2), (3) exclusions
 - o 'Technical'
 - o Two hurdles
 - o Computer program/signal claims
 - Arguments to the USPTO after Myriad and Alice
 - o Abstract limitations v. "something more"
 - o USPTO "guidance" on subject matter eligibility

Worked Examples

 Delegates will be invited to analyse and develop approaches for a sample application suitable for an EPO and USPTO prosecution